



**Mechanical date:**  $A_x=A_y=330\mu\text{m}$   
 $B_x=B_y=155\mu\text{m}$

**Schematic and pinning diagram**

**Chip thickness:** a)  $630\pm 20\mu\text{m}$  on 6" wafer – SM-3.3L12  
 b)  $138\pm 12$  on 4" wafer – SM-3.3L11

**Scribe Line width** - 50 $\mu\text{m}$ .

**Top Metal:** AL with Ti under layer metallization for wire bond, thickness 2,2-2,4 $\mu\text{m}$ .

**Back side - Anode:** a) without metallization – SM-3.3L12  
 b) Ti-Ni-Ag for soldering – SM-3.3L11

**Top Side (Cathode)** - pin 1, **Back Side (Anode)** - pin 2.

**Sampling testing:** no bad dice inking;  
 guaranteed good dice quantity  $\geq 95\%$ .

### Limiting values

Parameter	Symbol	Conditions	Value	Unit
Reverse Stand-off voltage	$V_{RWM}$	-	3,0	V
Peak Pulse Power	$P_{PP}$	$t_p=8/20\mu\text{s}$	250*	W
Peak Pulse Current	$I_{PP}$	$t_p=8/20\mu\text{s}$	15*	A
Electrostatic Discharge	$V_{ESD}$	IEC 61000-4-2, level 4.	$>\pm 15\text{kV}$ (Contact); $>\pm 15\text{kV}$ (Air).	kV
Max.junction temperature	$T_j$	-	+150	$^{\circ}\text{C}$

### Characteristics ( $T_a=25^{\circ}\text{C}$ )

SYMBOL	PARAMETER	CONDITIONS	MIN.	TYP.	MAX.	UNIT
$V_{BR}$	Breakdown voltage	$I_R=5\text{mA}$	4,85	-	6,0	V
$I_R$	Reverse leakage current	$V=3.0\text{V}$	-	-	1,0	$\mu\text{A}$
$V_F$	Forward voltage	$I_F=10\text{mA}$	-	-	1,0	V
$V_{CL}$	Clamping Voltage	$I_{pp}=1.0\text{A}$ , $t_p=8/20\mu\text{s}$ $I_{pp}=15\text{A}$ , $t_p=8/20\mu\text{s}$	-	-	6,7* 16,5*	V
$C_J$	Diode capacitance	$V_R=0\text{V}$ , $f=1\text{MHz}$	-	70	110	pF

\*- For Device testing